

**Hummer<sup>®</sup> Sputtering Tools** 

**Innovative Plasma Systems** 

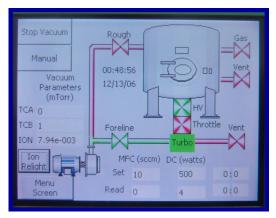
# Hummer BC-20 Series

ONE SYSTEM IN A FAMILY OF PLANAR MAGNETRON SPUTTERING SYSTEMS

## THIN FILM DEPOSITION OF METALS AND INSULATORS



BC Systems are available in sizes; 16", 20", 24" and 30" D-style chambers



TOUCH-PANEL SYSTEM CONTROL

Vacuum and Process Control all in one. Functions are clearly displayed

QUARTZING
CV DOT MATRIX
FAILURE ANALYSIS
MATERIALS RESEARCH
MICROELECTRONICS RE-

The **HUMMER BC-20** sputter coater combines a high degree of process control and flexibility with ease of operation.

THIN FILM RESEARCH - FAILURE ANALYSIS - PILOT SUPPORT

Web Site: www.anatechusa.com E-Mail: info@anatechusa.com

## **HUMMER® BC-20**

#### **PLANAR MAGNETRON SOURCE**

#### **OVERALL SYSTEM**

#### **VACUUM SYSTEM**

#### **TARGET DIAMETER** -

1/4" standard

3" Standard, Optional - 2" & 4" diameter sources and Multiple sources TARGET THICKNESS - 1/16 to

**TARGET MATERIALS** - Metals and / or insulators

**SOURCE MOUNTING** - Quick coupling to chamber, shutters, shields between sources as necessary

**POWER SUPPLY** - 300 watts, 13.56 MHz. Standard Optional - 600, 1000 watts RF at 13.56 MHz.

1500 Watts Standard, Optional - 2500 Watts DC, or various combinations of supplies **COOLING WATER** - .2 to 10

GPM required. Optional - Recirculation system

**TARGET MOUNTING** - Mechanical clamp or magnetic keeper depending upon requirement

**CHAMBER** - 304 Stainless steel, 20" ID nominal, aluminum door, 4" Door view port, roughing, High Vacuum pump and instrument ports

**CONTROL** - Siemens S7-200 gauges (2), Ion gauge (1).

Series PLC control for each vacuum function and sputtering source. Fully integrated with easy "Touch-Panel" control pad for diagnostic and setting system parameters

gauges (2), Ion gauge (1).

Atmosphere to 1 x 10<sup>-8</sup> TORR

VALVES - Electro-Pneumatic actual High Vacuum/Throttle valve between pump and chamber. Fore-land chamber roughing isolation valves. Pneumatic air or nitrogen

**DESIGN** - Floor mount cabinet on casters with leveling pads **SAFETY INTERLOCKS** - Water, door and vacuum interlocks.

**ELECTRICAL REQUIREMENTS** - 40-75 AMP, 208-240 Volt, 50/60 HZ

**SPUTTERING** - Standard top down sputtering. Optional - Sputter-up or horizontal sputter

**AUTOMATIC SEQUENCING** - Standard

**PUMPING** - Roughing pump and Turbo molecular pump - Standard Optional - Cryo pump or Larger pumps

VACUUM GAUGING - Convectron gauges (2), Ion gauge (1).
Atmosphere to 1 x 10<sup>-8</sup> TORR
VALVES - Electro-Pneumatic actuated
High Vacuum/Throttle valve between pump and chamber. Fore-line
and chamber roughing isolation
valves. Pneumatic air or nitrogen
(clean, dry) operating at 60-PSI.
GAS CONTROL - Mass Flow Controller
(1) 100 sccm. Optional - Gases (3)
maximum, for mixing and reactive
gas sputtering



## **STAGE FIXTURE**

**SIZE** - 2", 3", 4", 6", 8", 12" or 16" **MOTION** -360° rotation standard.

Optional - Variable angle of incidence to sputter source **COOLING** - Optional **REVERSE SPUTTER/ETCH** - Optional **HEATED** - Optional to 900° Celsius

## **IONIZATION SPECIES**

**GAS REQUIREMENTS** - Argon regulated from 5 to 20 PSI **OPERATING PRESSURE** -  $2 \times 10^{-3}$  to  $5 \times 10^{-2}$  **REACTIVE SPECIES** - Optional

## SOURCE OPTIONS

Anatech USA offers alternatives for source configuration. Contact our sales staff.



### CALL ANATECH USA TODAY TO DISCUSS YOUR APPLICATION

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